

ABSTRACT OF THE DISCLOSURE

A method of fabricating a liquid crystal display device includes forming an embossed reflective electrode. In the method, the embossed reflective electrode is embossed via a dry-etching method with a mixture of $\text{SF}_6 + \text{O}_2$ or $\text{CF}_4 + \text{O}_2$ gases, or with oxygen gas, such that a plurality of small concave and convex portions are formed on the reflective electrode. Since the concave and convex portions of the reflective electrode diffuse light, high luminance and wide viewing angle can be achieved.

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